L Number	Hits	Search Text	DB	Time stamp
1	369	((heat$3 adj (section or zone or chamber)) and (react$3 adj (section or zone or chamber) and puls$3 and (nozzle or inject$3 or inlet) not (((((422/198,194,190,110).CCLS.) and heat$3 and puls$3) ((((422/129,139,145,146,147) and heat$3 and puls$3) not (((422/129,139,14S,146,147) or (118/716)).CCLS.) and heat$3) and puls$3) ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716).CCLS.)) and (silicon near granule) (((((422/129,139,14S,146,147) or (118/716).CCLS.) and puls$3) (((((422/198,194,190,110).CCLS.) or (((422/129,139,14S,146,147) or (118/716)).CCLS.)) and heat$3 and puls$3) ((((422/198,194,190,110).CCLS.) and (silicon) and heat$3) not (((((422/198,194,190,110).CCLS.) and heat$3) not (((422/129,139,14S,146,147) or (118/716)).CCLS.) and heat$3) and puls$3) ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat$3) and puls$3)))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TD8	2004/01/08 10:1S
2	S8	((heat$3 adj (section or zone or chamber)) and (react$3 adj (section or zone or chamber)) and puls$3 and (nozzle or inject$3 or inlet) not (((((422/198,194,190,110).CCLS.) and heat$3 and puls$3) ((((422/129,139,145,146,147) and heat$3 and puls$3) not (((422/129,139,14S,146,147) or (118/716)).CCLS.) and heat$3) and puls$3) ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716).CCLS.)) and (silicon near granule) (((((422/129,139,14S,146,147) or (118/716).CCLS.) and puls$3) (((((422/198,194,190,110).CCLS.) or (((422/129,139,14S,146,147) or (118/716)).CCLS.)) and heat$3 and puls$3) ((((422/198,194,190,110).CCLS.) and (silicon) and heat$3) not (((((422/198,194,190,110).CCLS.) and heat$3) not (((422/129,139,14S,146,147) or (118/716)).CCLS.) and heat$3) and puls$3) ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat$3) and puls$3) ((heat$3 adj (section or zone or chamber)) and (react$3 adj (section or zone or chamber)) and puls$3 and (gas same (nozzle or inject$3 or inlet))) not ((((422/198,194,190,110).CCLS.) and heat$3 and puls$3) ((((422/198,194,190,110).CCLS.) and heat$3 and puls$3) not (((422/129,139,14S,146,147) or (118/716)).CCLS.) and heat$3) and puls$3)))) ((((422/198,194,190,110).CCLS.) or (((422/129,139,14S,146,147) or (118/716)).CCLS.) and puls$3) ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon) and heat$3) not (((((422/198,194,190,110).CCLS.) and heat$3) not (((422/129,139,14S,146,147) or (118/716)).CCLS.) and heat$3) ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat$3) and puls$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TD8	2004/01/08 10:16
3	4	(heat$3 adj (section or zone or chamber)) and (react$3 adj (section or zone or chamber) and puls$3 and ((nozzle or inject$3 or inlet))) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TD8	2004/01/08 10:2S

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-	2838	((422/129,139,145,146,147) or (118/716)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:46
-	1409	(((422/129,139,145,146,147) or (118/716)).CCLS.) and heat$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/06 17:38
-	94	(((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat$3) and puls$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 10:59
-	2	("20020081250").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/06 18:18
-	3254	(422/198,194,190,110).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:00
-	92	((422/198,194,190,110).CCLS.) and heat$3 and puls$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:01
-	87	(((422/198,194,190,110).CCLS.) and heat$3 and puls$3) not (((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat$3) and puls$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:01
-	2838	((422/129,139,145,146,147) or (118/716)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:46
-	8	((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 13:39
-	439	(((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon) not ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 11:01
-	94	(((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat$3) and puls$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 10:59

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-	324	((((422/198,194,190,110).CCLS.) or ((((422/129,139,145,146,147) or (118/716).CCLS.) and (silicon) and heat$3) not (((((422/198,194,190,110).CCLS.) and heat$3 and puls$3) not ((((422/129,139,145,146,147) or (118/716).CCLS.) and heat$3 and puls$3) ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716).CCLS.)) and (silicon near granule)) (((((422/129,139,145,146,147) or (118/716).CCLS.) and heat$3) and puls$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 12:39
-	319	(heat$3 adj (section or zone or chamber)) and (react$3 adj (section or zone or chamber)) and puls$3 and (gas same (nozzle or inject$3 or inlet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 12:47
-	311	((heat$3 adj (section or zone or chamber)) and (react$3 adj (section or zone or chamber)) and puls$3 and (gas same (nozzle or inject$3 or inlet))) not ((((422/198,194,190,110).CCLS.) and heat$3 and puls$3) not ((((422/129,139,145,146,147) or (118/716).CCLS.) and heat$3) and puls$3) ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716).CCLS.)) and (silicon near granule) (((((422/129,139,145,146,147) or (118/716).CCLS.) and heat$3) and puls$3) ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716).CCLS.)) and heat$3 and puls$3) not ((((422/129,139,145,146,147) or (118/716).CCLS.) and puls$3) ((((422/198,194,190,110).CCLS.) and heat$3 and puls$3) ((((422/129,139,145,146,147) or (118/716).CCLS.)) and (silicon near granule) (((((422/129,139,145,146,147) or (118/716).CCLS.) and heat$3) and puls$3))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/08 10:15
-	4	(heat$3 adj (section or zone or chamber)) and (react$3 adj (section or zone or chamber)) and puls$3 and (gas same (nozzle or inject$3 or inlet)) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/08 10:24

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